DOCKET NO: TS01-132

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.

10/040,042

Applicant

Wei-Yu Su

Filed

November 7, 2001

TC/A.U.

1746

Confirmation No.

1005

Title

1835

11110

Method for Reduction of Photomask Defects

Examiner

El Arini, Zeinab N1085-90003

Attorney Docket No :

111000

Customer No.

08933

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

## AMENDMENT AND RESPONSE UNDER 37 CFR 1.116(a)

In response to the Office Action of October 3, 2006, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 7 of this paper.